

Propriétés électrochimiques de couche mince ultrastable à base de réseaux métal-organiques générés in-situ par voie électrochimique

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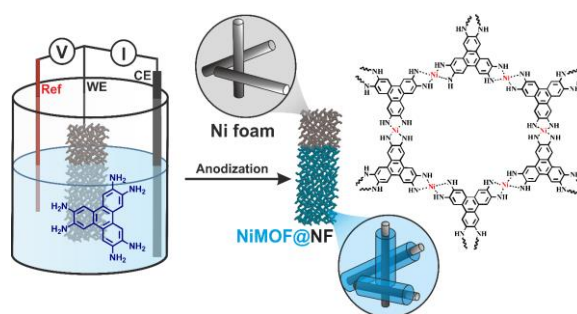
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Up-to-date, a great majority of materials for EDLCs devices are mainly composed of carbon-based ones^{1,2}, e.g. activated carbon, CNTs, and graphene. Even though they possess high theoretical surface area, the experimental capacitance could not reach theoretical values, mainly due to severe problems³⁻⁵, such as π -stacking, short/disordered ion-conduction channels, low packing density, etc. In parallel with the development of new synthetic procedure and/or processing methods using these materials, it is strongly expected to develop novel materials that could also satisfy the two crucial criteria. Indeed, a highly porous, additive-free and thin layer electrode with superior stability could response to all requirements.

In the last decade, metal organic frameworks (MOFs) have widely been investigated in a large range of applications thanks to their large specific surface area ($\sim 7,800 \text{ m}^2 \cdot \text{g}^{-1}$ up-to-date⁶ and can further reach a theoretical value of $\sim 15,000 \text{ m}^2 \cdot \text{g}^{-1}$)⁷ as well as a capability to modulate the physical chemical properties by tuning their structure. Nevertheless, excepting few examples, pristine MOFs are rarely used in supercapacitor application, resulting mainly from their low electrical conductivity ($< 10^{-2} \text{ S} \cdot \text{cm}^{-1}$)⁸.

In the present work, the $\text{Ni}_3(\text{HITP})_2$ MOF was successfully electrosynthesized via a one-pot approach from and to the surface of nickel foam (NF) and served as ultra-stable thin film electrode (Figure). The presence of the active layer is evidenced by a wide range of technique ranging from morphological, spectroscopic to electrochemical ones. As the film was formed within the diffusion layer of the NF surface, the electrochemical accessible surface area was improved and the drawback of being low electrically conductive of MOF based materials could be minimized. Accordingly, it is confirmed by a significant charge accumulation over dissipation obtained by electrochemical impedance microscopy and a capacitance retention about 40 % from 0.01 to 10 $\text{V} \cdot \text{s}^{-1}$. Besides, this approach allows the formed materials to be strongly attached to the surface of the current collector, thus significantly enhance the cycling stability around 100 % capacitance retention over 0.9 V for 170,000 cycles.



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